

595

Patent Number(s): US2012167261-A1

Title: Method for measuring interaction e.g. infrared radiation, with sub-micron region sample on substrate with probe atomic force microscope, involves measuring probe response due to interaction enhanced electric field with sample

Inventor Name(s): BELKIN M; LU F; YAKOLEV V V; PRATER C; KJOLLER K

Patent Assignee(s): BELKIN M (BELK-Individual); LU F (LUFF-Individual); YAKOLEV V V (YAKO-Individual); PRATER C (PRAT-Individual); KJOLLER K (KJOL-Individual)

Derwent Primary Accession No.: 2012-H44670

Abstract: NOVELTY - The method involves interacting an electric field enhancing tip (2) a probe microscope with a region a sample (4). The tip and the region the sample are illuminated with a source modulated infrared radiation. An electric field induced by the infrared radiation is enhanced in a region surrounding an apex the tip. A probe response due to the interaction the enhanced electric field with the sample is measured. A metallic coating is provided on the tip, where the metallic coating comprises a metal chosen from a list gold, silver, copper, platinum and palladium.

USE - Method for measuring interaction radiation e.g. infrared, UV, visible, and terahertz (all claimed), with a sub-micron region a sample on a sample substrate with a cantilever probe a probe microscope i.e. atomic force microscope (AFM).

ADVANTAGE - The method enables providing enhancement to significantly reduce illumination power levels, thus improving spatial resolution by confining a sample-radiation interaction to the region field enhancement. The method enables obtaining spectral information about the sample surface and the sample tip, thus creating high resolution spectral maps sample composition. The method enables enhancing detection in a small area near the tip-sample contact, thus paving the way for the use much broader array samples and sample substrate.

DETAILED DESCRIPTION - The source infrared radiation is selected from quantum cascade laser, optical parametric oscillator, global and Fourier Transform Infrared Spectrometer and pulsed source. The radiation is selected from UV, visible, and terahertz.

DESCRIPTION DRAWING(S) - The drawing shows a schematic view an atomic force microscope.

Electric field enhancing tip (2)

Sample (4)

Drawing:

Derwent Class Code(s): S02 (Engineering Instrumentation, ing equipment, general testing methods); S03 (Scientific Instrumentation, photometry, calorimetry)

Derwent Manual Code(s): S02-F01; S03-E02F3

IPC: G01Q-070/08

Patent Details:

Patent Number	Publ. Date	Main IPC	Week	Page Count	Language
US2012167261-A1	28 Jun 2012	G01Q-070/08		201244 Pages: 18	English

Application Details and Date:

US2012167261-A1	US307464	30 Nov 2011
-----------------	----------	-------------

Further Application Details:

US2012167261-A1	CIP	Application	US135956
-----------------	-----	-------------	----------

US2012167261-A1 Cont Application US803421

US2012167261-A1 Cont Patent US8001830

Priority Application Information and Date:

US803421 15 May 2007

US307464 30 Nov 2011